

L Number	Hits	Search Text	DB	Time stamp
6	26	((POSS (polyderal near oligomeric near silsesquioxane)) same (radiation photosensitive light methacrylate (meth near acrylate) ultraviolet)) and (silicate silicalite)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/06/04 08:59
7	38	((POSS (polyderal near oligomeric near silsesquioxane)) same (radiation photosensitive light methacrylate (meth near acrylate) ultraviolet)) and binder	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/06/04 08:59
8	28	(silicalite and dielectric) and binder	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/06/04 08:59
9	74	((POSS (polyderal near oligomeric near silsesquioxane)) same (radiation photosensitive light methacrylate (meth near acrylate) ultraviolet)) and dielectric	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/06/04 08:59
10	49	((binder) same (radiation photosensitive light ultraviolet)) and dielectric) and inhomogeneous	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/06/04 09:00
11	14	((binder) same (radiation photosensitive light ultraviolet))) same \$silsesquioxane	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/06/04 09:00
12	15	((\$silsesquioxane) same ((radiation photosensitive light ultraviolet UV!) near (curable cured curing crosslinked crosslinking crosslink polymerizing polymerizable))) and (silica silicate silicalite)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/06/04 09:00
13	26	((((POSS (polyderal near oligomeric near silsesquioxane)) same (radiation photosensitive light methacrylate (meth near acrylate) ultraviolet)) and (silicate silicalite)) ((POSS (polyderal near oligomeric near silsesquioxane)) same (radiation photosensitive light methacrylate (meth near acrylate) ultraviolet)) and binder) ((silicalite and dielectric) and binder) ((POSS (polyderal near oligomeric near silsesquioxane)) same (radiation photosensitive light methacrylate (meth near acrylate) ultraviolet)) and dielectric) (((binder) same (radiation photosensitive light ultraviolet)) and dielectric) and inhomogeneous) (((binder) same (radiation photosensitive light ultraviolet))) same \$silsesquioxane) (((\$silsesquioxane) same ((radiation photosensitive light ultraviolet UV!) near (curable cured curing crosslinked crosslinking crosslink polymerizing polymerizable))) and (silica silicate silicalite))) and @pd>20031212	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/06/04 11:02
14	32464	porous same (silica silicate silicalite)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/06/04 11:01
15	54750	((binder) same (radiation photosensitive light ultraviolet))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/06/04 11:19
16	109	(porous same (silica silicate silicalite)) same (((binder) same (radiation photosensitive light ultraviolet)))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/06/04 11:02

17	109	((porous same (silica silicate silicalite)) same (((binder) same (radiation photosensitive light ultraviolet))) not (((POSS (polyderal near oligomeric near silsesquioxane)) same (radiation photosensitive light methacrylate (meth near acrylate) ultraviolet)) and (silicate silicalite)) (((POSS (polyderal near oligomeric near silsesquioxane)) same (radiation photosensitive light methacrylate (meth near acrylate) ultraviolet)) and binder) ((silicalite and dielectric) and binder) (((POSS (polyderal near oligomeric near silsesquioxane)) same (radiation photosensitive light methacrylate (meth near acrylate) ultraviolet)) and dielectric) (((binder) same (radiation photosensitive light ultraviolet)) and dielectric) and inhomogeneous) (((binder) same (radiation photosensitive light ultraviolet))) same \$silsesquioxane) (((\$silsesquioxane) same ((radiation photosensitive light ultraviolet UV!) near (curable cured curing crosslinked crosslinking crosslink polymerizing polymerizable))) and (silica silicate silicalite)))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/06/04 11:02
18	33021	((binder) same (radiation photosensitive ultraviolet))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/06/04 11:19
19	32	(porous same (silica silicate silicalite)) same (((binder) same (radiation photosensitive ultraviolet)))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/06/04 11:19